

Symposium U

Metal Oxide Nanomaterials for Advanced Optoelectronics & Environmental Applications

Hot topics to be covered by the symposium:

- Fabrication and characterization of thin film metal oxides including different deposition methods (magnetron sputtering, ALD, spray pyrolysis, sol gel method etc),
- Nanowires, nanoparticles and other nanostructures,
- · Bandgap engineering in oxides using doping, strain and heterostructures formation,
- Enhanced performance of light emitting diodes and thin film transistors,
- Transparent conductive oxide,
- · Materials for photocatalysis and photoelectrochemistry,
- Oxides for supercapacitors and battery application,
- Piezoelectric ceramics,
- · Oxides for high power electronics and beyond,
- Phase change oxides.

Symposium organizers

David HORWAT Université de Lorraine, CNRS IJL, F-54000 Nancy, France

Mail : david.horwat@univlorraine.fr Jung Hyuk KOH Chung-Ang University 84, Heukseok-ro, Dongjak-gu, Seoul, 06974, Rep. of Korea

Mail : jhkoh@cau.ac.kr

Raul GAGO

Instituto de Ciencia de Materiales de Madrid

Consejo Superior de Investigaciones Científicas, Cantoblanco, 28049 Madrid, Spain

Mail : rgago@icmm.csic.es

Renata RATAJCZAK National Centre for Nuclear Research

A. Soltana 7, 05-400 Otwock, Poland

Mail : renata.ratajczak@ncbj.gov.pl

Slawomir PRUCNAL (Main Organizer)

Institute of Ion Beam Physics and Materials Research

Helmholtz-Zentrum DresdenRossendorf Bautzner Landstrasse 400, 01328 Dresden, Germany

Mail : s.prucnal@hzdr.de